

Attorney Docket No. 10112461

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Shlan-Jyh LIN, Hai-Han HUNG,
Chung-Yuan LEE

Filed: 7/16/2003

RECEIVED
CENTRAL FAX CENTER

Appl. No.: 10/620,518

Examiner:

JAN 24 2005

Conf. No.: 9014

Art Unit: 2812

Title: METHOD FOR FORMING A SILICON NITRIDE LAYER

Date: January 24, 2005

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

STATUS INQUIRY

Sir:

The above-identified patent application, filed on July 16, 2003, has not yet been docketed.

Applicant respectfully inquires as to the status of the above-identified patent application and when the next communication from the United States Patent and Trademark Office can be expected.

Certificate of Transmission

I hereby certify that this correspondence is being facsimile transmitted to the United States Patent & Trademark Office to 1-703-872-9306 on the date shown below:

Nelson A. Quintero

(Name of Person Transmitting)

(Signature)

January 24, 2005

(Date)

Respectfully submitted,

Nelson A. Quintero
Attorney for Applicant
Reg. No. 52,143
Customer No. 34,283

Telephone: (310) 401-6180

P109039NAQ